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Eight volumes per year.

Publication information: Journal of Photochemistry and Photobiology A: Chemistry (ISSN 1010-6030). For 2010, volumes 209–216(24 issues) are scheduled for publication. Subscription prices are available upon request from the Publisher or from the Elsevier Customer Service Department nearest you or from this journal's website (http://www.elsevier.com/locate/jphotochem). Further information is available on this journal and other Elsevier products through Elsevier's website (http://www.elsevier.com). Subscriptions are accepted on a prepaid basis only and are entered on a calendar year basis. Issues are sent by standard mail (surface within Europe, air delivery outside Europe). Priority rates are available upon request. Claims for missing issues should be made within six months of the date of dispatch.

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